

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re the application of:) **CONFIRMATION NO.: 4956**
)
Hiromitsu NANBA, et al.)
)
U.S. Serial No.: 10/577,314) Group Art Unit: 1792
)
Filed: April 28, 2006) Examiner: Eric W. Golightly

For: SUBSTRATE CLEANING METHOD, SUBSTRATE CLEANING APPARATUS AND
COMPUTER READABLE RECORDING MEDIUM

RESPONSE TO RESTRICTION REQUIREMENT

Commissioner for Patents
P.O. Box 1450
Alexandria, VA 22313-1450

Sir :

A response to the Office Action mailed July 7, 2009 is due by August 7, 2009. The Action required restriction among five patentably distinct inventions.

Applicants hereby elect without traverse Group I of claims 1-10, drawn to a substrate cleaning method, for examination in this application. Applicants advise that no change in the inventorship of the application will be required by the eventual cancellation of non-elected claims.

Applicants reserve the right to file divisional application(s) for the non-elected claims in due course.

It is submitted that this application now is in condition for examination on the merits and early action in that regard is solicited.

Respectfully submitted,

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